

Contents

1	Introduction	1
1.1	Transparent Electrodes	1
1.1.1	Applications and Market	2
1.1.2	State of Art and its Drawbacks	3
1.1.3	Materials for ITO Replacement	4
1.2	Aim of the Thesis	6
1.3	Thesis Outline	7
	References	8
2	Basics of Ultrathin Metal Films and Their Use as Transparent Electrodes	11
2.1	Definition of Ultrathin Metal Films	11
2.2	Deposition of UTMFs	12
2.3	Growth of UTMFs	15
2.4	Surface Analysis of UTMFs	16
2.5	Flexibility Analysis of UTMF	18
2.6	Electrical Analysis of UTMFs	18
2.6.1	Electrical Conductivity Mechanisms of UTMFs	18
2.6.2	Sheet Resistance Measurement	22
2.7	Optical Analysis of UTMFs	23
2.8	Stability	26
2.9	Use in OLED Device	30
2.10	Conclusions	30
	References	31
3	UTMF-Based Transparent Electrode Incorporating a Metallic Grid	33
3.1	Motivation	33
3.2	Design of the Grid	35
3.3	Implementation	39
3.4	Experimental Results	40
3.5	Conclusions	41
	References	42

4	Copper Bilayer Transparent Electrodes	43
4.1	Motivation	43
4.2	Implementation	43
4.3	Experimental Results and Analysis	44
4.4	Performance in OLED and OPV Devices	49
4.5	Conclusions	50
	References	50
5	Ultrathin Alloy Films as TEs	51
5.1	Motivation	51
5.2	Optical Spectra	52
5.3	Implementation	53
5.4	Optical, Electrical and Mechanical Performance	54
5.5	Performance in an OPV Device.	57
5.6	Conclusions	57
	References	58
6	Ag/Al:ZnO Nano-Thick Bilayer TEs	59
6.1	Motivation	59
6.2	Implementation	59
6.3	Experimental Results and Analysis	60
6.4	Performance in an OPV Device.	65
6.5	Conclusions	66
	References	66
7	Ultrathin Metal Capped Al-Doped ZnO as Transparent Electrode	69
7.1	Motivation	69
7.2	Implementation	70
7.3	Experimental Results and Stability Analysis	70
7.4	Performance in OLED and OPV Device.	76
7.5	Conclusions	77
	References	78
8	Summary and Future Outlook	79
	Curriculum Vitae	81

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